

## **ACKNOWLEDGEMENTS**

I thank my advisor, David F. Cox, for giving me the opportunity to work in a very interesting area, and for his support and guidance throughout my graduate studies at Virginia Tech.

I thank the members of my committee for their time and effort as well as the D.O.E. for the financial support of my work.

I thank my parents for their love and support while I decided to be a “professional” student for awhile.

I thank Steve York, Mark Abee, and Todd St. Clair for making the lab a tolerable and even at times an enjoyable place to come to each day.

I thank Kevin Rosso and the other “rock-boys” in Geology for their invaluable help during the STM portion of this study.

Finally, I thank all the friends I’ve met over my many years at Virginia Tech especially Joe Edwards, Jeremy Koren, Wes Lang, and Justin Nave. I learned a great deal from each of you, none of which I can remember now.

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